XAFS Study on Re/Zeolite Catalysts for Direct Phenol Synthesis from Benzene with Molecular Oxygen

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Introduction

Phenol is an important chemical in industry but has been produced from benzene by the three-steps of cumene process. Direct phenol synthesis from benzene is one of the important subjects. However, no selective catalyst with good performance in an economically and environmentally favourable benzene-O₂ system has been discovered to date. We have found Re/HZSM-5 promoted the direct phenol synthesis from benzene with 88% (steady-state) and 94% (pulse) selectivity using molecular oxygen as an oxidant under co-existing NH₃.

Experimental

HZSM-5 supported Re catalysts were prepared by a conventional impregnation method using NH4ReO4 and a CVD method with CH3ReO3 at 333 K. The both catalysts were pretreated in a He flow at 673 K for 1 h. The selective catalytic reactions were conducted in a fixed bed down flow reactor with the reaction gases of He: O2: NH3: benzene = 46.4: 12.0: 35.0: 6.6 (mol%), analyzed by on-line GC.

XAFS spectra at Re LIII-edge were measured in a transmission mode at 15 K at the BL-10B and 12C stations. The samples were measured without exposing to air. Background subtraction was conducted by the AUTOBK program, and Fourier-transformed spectra were fitted in R space by FEFFIT program.

Results and Discussion

It was found that Re/HZSM-5 catalysts are active for the selective oxidation of benzene with molecular oxygen when ammonia was coexisted. The CVD catalyst was almost 18 times more active than the impregnated catalyst. The selectivity was much higher on the CVD catalyst (88%) than on the impregnated catalyst (28%). The catalytic performances depended on the kind of zeolites.

Figure 1 shows Re LIII-edge EXAFS Fourier transforms and curve fitting spectra for the CVD Re/ZSM-5 sample after NH3 treatment and the steady state oxidative reaction. It is obvious that the structure of the Re species changes remarkably by NH3. The NH3 treatment caused a drastic transformation to Re cluster with Re-Re bonds at 0.276±0.001 nm (CN=5.1±0.3). There were two types of Re-O bonding attributed to Re=O at 0.173±0.001 nm (CN=0.5±0.2) and longer Re-Obridge and/or Re-Olattice at 0.202±0.001 nm (CN=2.4±0.3). The structure of the Re cluster was modelled by DFT as a N-interstitial Re9 cluster

composed of two octahedral Re6 frameworks with plane share to each other. The treatment with NH3 at 553 K reduces Re oxidation state to the lower valence proved by ReL, XANES and XPS.



Figure 1. Fourier-transformed Re LIII-edge EXAFS spectra of Re cluster after the NH3 treatment (top) and Re monomer after the reaction (bottom).

The NH3 pretreated catalyst did not produce phenol when only benzene was pulsed. This indicates that the lattice oxygen of the Re cluster is not involved for the selective oxidation. The pulse of benzene + O2 on the NH3 pretreated catalyst produced phenol with 94% selectivity, which demonstrates that the Re cluster is active species.

In the pulse experiment the phenol formation rate became zero after 4 pulses. Thus the coexistence of NH3 is indispensable for the phenol formation, and the Re cluster is not stable under O2 in the absence of NH3. The active Re cluster was transformed to inactive Re monomers with Re=O bonds at 0.173±0.001 nm (CN=3.7±0.2) and Re-O bond at 0.213±0.003 nm (CN= 1.3 ± 0.7) as proved by EXAFS.

In presence of ammonia about 3 - 4 % of the [ReO4] monomers are estimated to be transformed to Re9 clusters, which are responsible for the formation of phenol. A mechanism for the phenol formation may involve oxygen free radical formation on Re9 cluster. Alternatively, molecular oxygen associatively adsorbed on the partially reduced Re9 cluster may be the active oxygen species for the formation of phenol from benzene. On the latter case the maximum selectivity would be 93.9%.

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